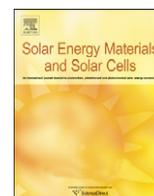




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Letter

Effects of Mg composition on open circuit voltage of $\text{Cu}_2\text{O}-\text{Mg}_x\text{Zn}_{1-x}\text{O}$ heterojunction solar cellsZiqing Duan^a, Aurelien Du Pasquier^b, Yicheng Lu^{a,*}, Yi Xu^c, Eric Garfunkel^c^a Department of Electrical and Computer Engineering, Rutgers University, 94 Brett Road, Piscataway, NJ 08854, USA^b Department of Materials Science and Engineering, Rutgers University, 671 US Highway 1, North Brunswick, NJ 08902, USA^c Department of Chemistry and Chemical Biology, Rutgers University, 610 Taylor Road, Piscataway, NJ 08854, USA

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ABSTRACT

$\text{Mg}_x\text{Zn}_{1-x}\text{O}$ ($0 \leq x \leq 0.13$) films grown by metal-organic chemical vapor deposition (MOCVD) were chosen as the n-type semiconductor layer forming a heterojunction with electrodeposited p-type cuprous oxide (Cu_2O) for photovoltaic applications in this study. We investigated the effects of Mg contents (x) on the performance of $\text{Ag}-\text{Cu}_2\text{O}-\text{Mg}_x\text{Zn}_{1-x}\text{O}$ -fluorine-doped tin oxide (FTO)-glass heterojunction solar cells, where Ag and FTO are used as top and bottom electrodes, respectively. An enhancement of the open-circuit voltage (V_{OC}) with the increase of x , from 251 mV at $x=0$ to 570 mV at $x=10\%$, was observed. In order to understand how V_{OC} increases with Mg%, the band alignment between Cu_2O and $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ was demonstrated using X-ray photoelectron spectroscopy (XPS) measurements. The result indicates that the conduction band of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ moves closer to the vacuum level with increasing of x , leading to a decrease of the conduction band offset between $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ and Cu_2O and hence an enhancement of theoretical V_{OC} . Another improvement with the increase of Mg% was realized on the shunt resistance (R_{sh}) of devices. With the improved V_{OC} and R_{sh} , a relatively high solar power conversion efficiency ($\eta_{\text{AM1.5}}=0.71\%$) was obtained on the $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ ($x=10\%$) based solar cell.

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1. Introduction

ZnO, a wide bandgap semiconductor (~ 3.3 eV at room temperature), is also a promising photovoltaic (PV) material when used as an electron acceptor and conductor [1]. It has been demonstrated that n-type ZnO and p-type Cu_2O form heterojunction solar cells, with Cu_2O as the photon absorber [2,3]. A solar conversion efficiency of $\sim 2\%$ was recently reported for $\text{Cu}_2\text{O}-\text{ZnO}$ solar cells [2]; however, it is still one order of magnitude lower than the theoretical limit of Cu_2O solar cells ($\sim 20\%$) [4]. The low solar conversion efficiency of $\text{Cu}_2\text{O}-\text{ZnO}$ solar cells was attributed to the high defect density in polycrystalline Cu_2O thin films and low quality of the $\text{Cu}_2\text{O}-\text{ZnO}$ heterojunction resulted from non-optimal deposition, and inefficient minority carrier transport caused by the planar interface structure [5–9]. Various strategies have been used to improve the solar conversion efficiency (η) of $\text{Cu}_2\text{O}-\text{ZnO}$ heterojunctions, such as using post-deposition cyanide treatment [5], improving the electrical properties of Cu_2O films by optimizing deposition conditions [6,3], refining deposition conditions of the ZnO layers [7,8] and applying a nanowire architecture

to the $\text{Cu}_2\text{O}-\text{ZnO}$ interface [9]. In this paper, we report another method to increase the efficiency of $\text{Cu}_2\text{O}-\text{ZnO}$ solar cells using the ternary alloy $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ to replace the ZnO, thus, increasing the open circuit voltage V_{OC} .

$\text{Mg}_x\text{Zn}_{1-x}\text{O}$, which is formed by alloying MgO with ZnO, has been developed as a promising semiconductor for barrier layers in ZnO/ $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ quantum wells or superlattices due to its wider bandgap (increasing from 3.3 eV for ZnO up to ~ 4.0 eV as $x=0.33$ for the direct energy bandgap) [10,11]. It has been observed that the conduction band minimum (CBM) of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ moves closer to the vacuum level with increasing Mg composition x when it forms the heterojunction with other semiconductors such as ZnO [11] and CdS [12]. Olson et al. also found the same trend after they measured the work function of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films deposited on ITO and saw a decreased work function with increasing Mg composition [13]. They reported that the moving of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ CBM led to a reduced conduction band offset and an enhanced V_{OC} in $\text{Mg}_x\text{Zn}_{1-x}\text{O}-\text{P3HT}$ hybrid solar cells. The $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ film has also been used as a window layer in $\text{Cu}(\text{In}, \text{Ga})\text{Se}_2$ solar cells to tune the conduction band offset for higher V_{OC} and efficiency [14,15]. However, there has been no report on the energy band alignment of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ in $\text{Mg}_x\text{Zn}_{1-x}\text{O}-\text{Cu}_2\text{O}$ heterojunction. In this paper, we report the band alignment between $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ and Cu_2O determined using X-ray photoelectron spectroscopy

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(XPS), from which we investigate the Mg composition effect on the performance of $\text{Mg}_x\text{Zn}_{1-x}\text{O}-\text{Cu}_2\text{O}$ heterojunction solar cells.

Cu_2O thin films have been grown by various methods including the thermal oxidation of Cu foils [16], metal-organic chemical vapor deposition (MOCVD) [17], sputtering [18] and electrochemical deposition [19]. Among them, the electrodeposition is the attractive technique because of its ability to use low-cost equipment and chemicals, large area coating and precise control of deposition parameters. In design of the cell structure, the deposition sequence of p- Cu_2O on ZnO films is chosen based on two considerations: first, p- Cu_2O on ZnO shows smaller lattice mismatch than the inverse structure and hence lower density of interface defects and a better solar cell performance [18]; second, this deposition sequence can avoid formation of the impurity phase CuO at the interface that usually occurs in the inverse sequence.

2. Experimental

$\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films were grown on $1'' \times 1''$ fluorine-doped tin oxide (FTO)/glass substrates (Pilkington TEC7) by the MOCVD technique at temperature of $\sim 520^\circ\text{C}$. Diethylzinc (DEZn) and bis(methylcyclopentadienyl)magnesium (MCp_2Mg) were chosen as the Zn and Mg precursors, respectively. Oxygen gas was used as the oxidizer and injected into the chamber with a separate line to avoid the gas phase reactions. The Mg composition

($0 \leq x \leq 0.13$) was tuned by changing the precursor flow rate ratio ($\text{MCp}_2\text{Mg}/\text{DEZn}$). All $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films were kept ~ 600 nm thick. Cu_2O films were electrodeposited from aqueous solutions of CuSO_4 (0.4 mol L^{-1}) and lactic acid (3 mol L^{-1}), with the pH value ~ 11 – 12 controlled by NaOH. The working electrode substrates were $\text{Mg}_x\text{Zn}_{1-x}\text{O}/\text{FTO}/\text{glass}$. The counter electrode was a Cu foil. Electrodeposition was performed at a constant voltage of -0.4 V with the bath temperature of 90°C , under which a growth rate of $\sim 0.2 \mu\text{m}/\text{min}$ was obtained. The thickness of ~ 4.2 – $4.5 \mu\text{m}$ was controlled for all Cu_2O films. Metal contacts (Ag) were then deposited by a Hummer Anatech 6.6 argon plasma sputtering system. Devices were annealed for 15 min at 200°C in air. Film thickness measurements were performed with a Veeco D150 stylus profilometer. X-ray diffraction (XRD) patterns were acquired on a Siemens D500 X-ray diffractometer. A Hitachi (S-800) field emission scanning electron microscopy (FESEM) was used to check the morphology of Cu_2O and $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films. Hall measurements on the Van der Pauw patterns were conducted to characterize the electrical properties of Cu_2O and $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films. The room temperature transmission spectra of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films were measured using a UV/vis spectrophotometer (BECKMAN DU 530). The XPS measurements were performed on a XPS spectrometer (Thermo Scientific Inc. K-Alpha) with a monochromatized Al K α (1486.6 eV) source. J – V testing was conducted with an EG&G 273A potentiostat using the full spectrum of a xenon light source shaped with a AM1.5 filter and adjusted to $100 \text{ mW}/\text{cm}^2$ with a Newport thermopile. AM1.5 is

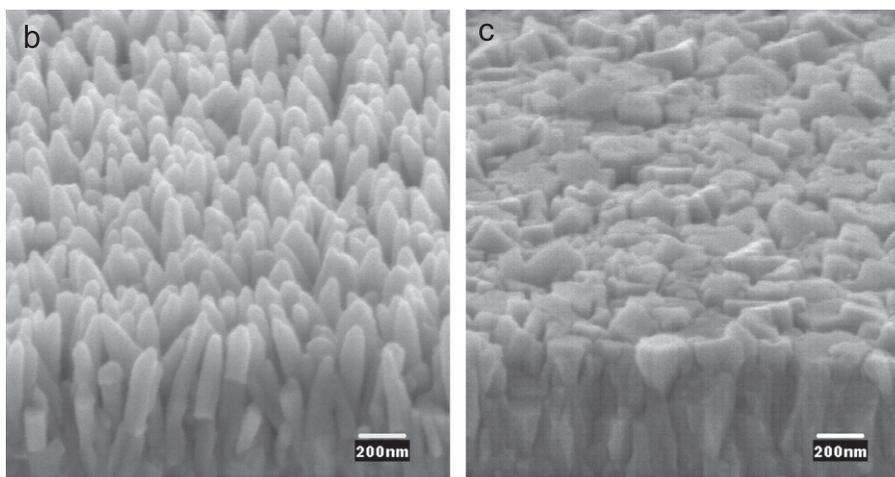
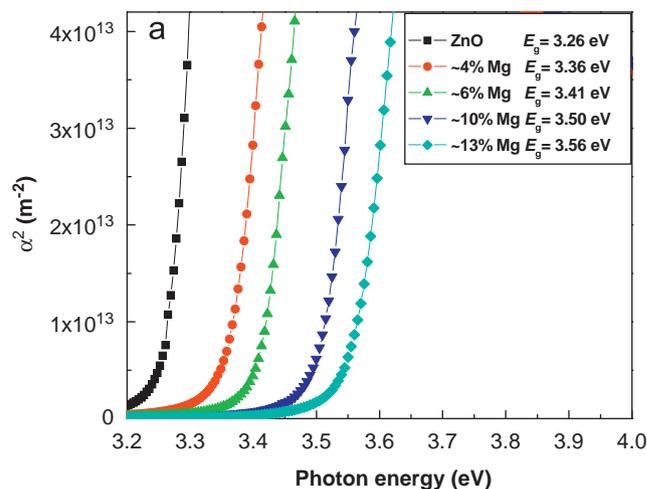


Fig. 1. (a) Plots of α^2 versus $h\nu$ for $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ ($0 \leq x \leq 0.13$) films; FESEM images of as-grown $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ layers with (b) $x=0$ and (c) $x=0.10$.

defined as the incident solar flux at the Earth's surface at incident angle of 37° to the equator, and 100 mW/cm^2 is the power of 1 Sun irradiation under those conditions.

3. Results and discussion

The transmission spectra of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films were measured at room temperature with a UV-visible spectrophotometer. A transmittance of $> 80\%$ in the visible light region is observed on all films, which allows most of the visible light transmitted into the light-absorber layer (Cu_2O) of the solar cell. The bandgap values of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ films are determined by plotting the absorption coefficient α^2 as a function of photon energy ($h\nu$) and fitting these curves to the equation $\alpha = A^*(h\nu - E_g)^{1/2}$, where A^* is a frequency-independent constant, as shown in Fig. 1a. Fig. 1b and c shows the FESEM (field emission scanning electron microscopy) images of as-grown $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ with $x=0$ and $x=0.1$, respectively. It is observed that the $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ surface morphology evolves with increasing of the Mg composition x . During MOCVD growth, nanostructured ZnO is formed at temperature $400\text{--}500^\circ\text{C}$ [20], resulting from the polarity of ZnO along $\langle 0001 \rangle$ direction. This leads to a high surface energy on $\{0001\}$ planes [21] and hence a fast growth rate along the c -axis [22]. With the Mg incorporation into ZnO, however, this polarity is weakened, leading to the reduction of the anisotropy of surface energy among all ZnO planes [23]. The growth rates along a - and b -axis would increase, while that along the c -axis decreases. As a result, the morphology of $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ changes

from sharp nanotip arrays to dense columns with increasing x , as shown in Fig. 1b and c.

Fig. 2a shows the plot of the absorption coefficient α^2 as a function of photon energy ($h\nu$), from which the bandgap of Cu_2O is determined to be 2.0 eV by extrapolating the adsorption edge. Fig. 2b shows the dense Cu_2O film ($\sim 4.5 \mu\text{m}$ thick) deposited on $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ -FTO-glass substrates, taken by FESEM. The XRD pattern of Cu_2O film (Fig. 2c) shows the pure Cu_2O phase. None of the other phases, such as CuO or Cu are detected although these two impurities could easily be incorporated into Cu_2O during the deposition process [3]. XPS was used to verify the purity of Cu_2O , as shown in Fig. 2d. The Cu $2p_{3/2}$ peak is fit into a single peak at a binding energy of 932.42 eV with a FWHM of 1.27 eV as known from literature values for Cu(I) in Cu_2O [24]. No sub-peak at a binding energy of 933.73 eV , which is attributed to the Cu(II) in CuO, is observed. Moreover, the shake-up satellites peaks that usually appear in CuO and at a binding energy 940 eV – 945 eV [25] are not seen in this spectrum. Another possible impurity, Cu, is not easy to quantify by XPS because the Cu $2p_{3/2}$ peak binding energies of Cu(0) and Cu(I) are very close ($\sim 0.1 \text{ eV}$ difference). But these two states can be distinguished from the Cu LMM-2 Auger transition peak positions, which also appear in photoemission spectra; the peak positions are 568 eV for Cu (metal) and 570 eV for Cu_2O [26]. In our sample, a broad peak centered at 570 eV was found. Although a small peak at 568 eV is possibly buried in the broad peak, it appears that the amount of Cu is negligible.

The current density–voltage (J - V) curves of the heterojunction devices are shown in Fig. 3 and various parameters of the solar cells examined are listed in Table 1. As expected, the V_{OC} value increases with increasing Mg content, from 251 mV for the pure

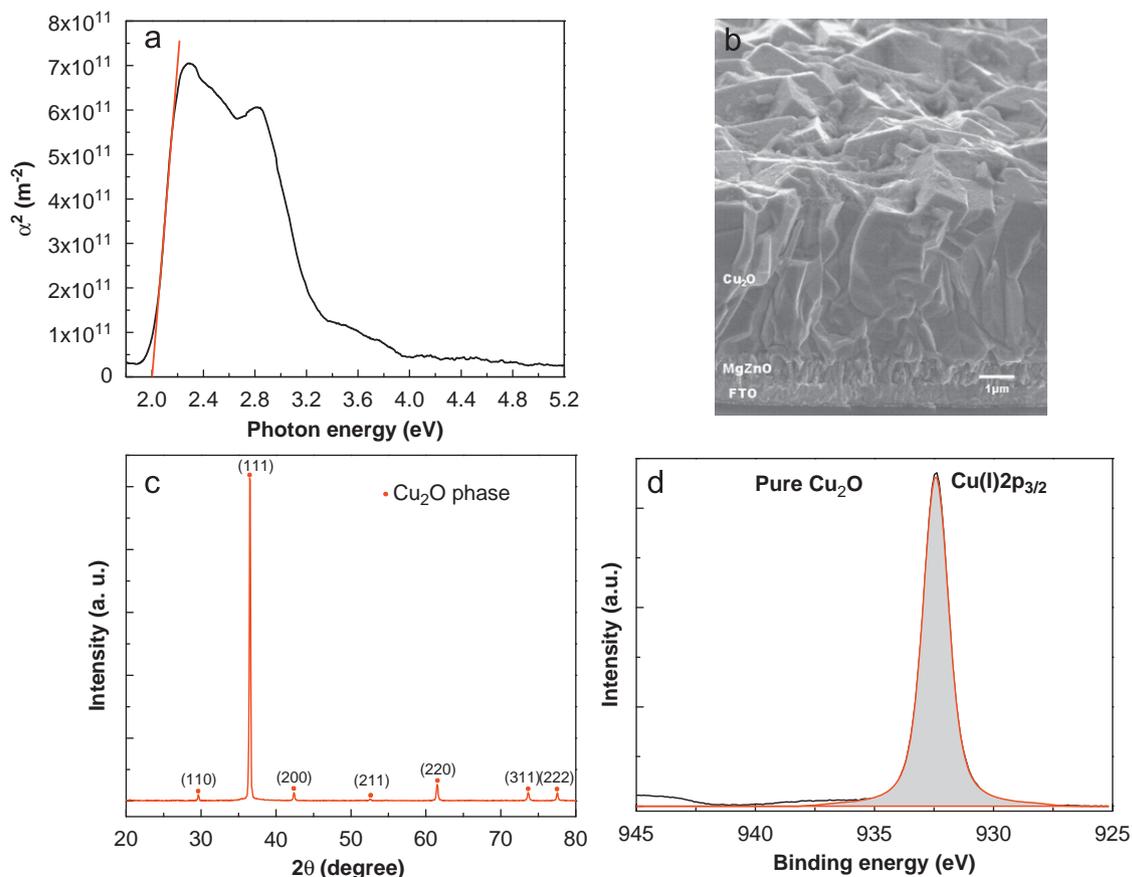


Fig. 2. (a) A plot of α^2 versus photon energy ($h\nu$) for the Cu_2O film; (b) an FESEM image of the Cu_2O film deposited on $\text{Mg}_{0.1}\text{Zn}_{0.9}\text{O}$ -FTO films; (c) a typical XRD pattern of the Cu_2O film; (d) the Cu $2p_{3/2}$ XPS spectrum from a Cu_2O film.

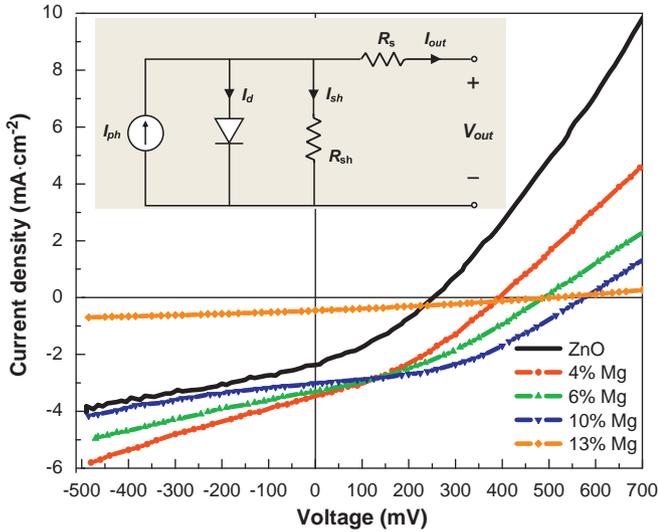


Fig. 3. Current density (J)-voltage (V) characteristics of FTO/Mg_xZn_{1-x}O-Cu₂O/Ag solar cells under AM1.5 simulated sunlight. The inset shows the equivalent circuit of the solar cell, where I_{ph} , I_d and I_{sh} are photogenerated current, dark current and shunt current, respectively.

Table 1

Photovoltaic parameters of the FTO/Mg_xZn_{1-x}O-Cu₂O/Ag solar cells with different Mg composition x examined under AM1.5 simulated sunlight.

% Mg	η (%)	FF	J_{sc} (mA/cm ²)	V_{oc} (mV)	R_s (Ω cm ²)	R_{sh} (Ω cm ²)
0	0.21	0.34	2.38	251	60	189
4	0.47	0.34	3.44	390	64	223
6	0.57	0.35	3.30	488	91	350
10	0.71	0.42	3.00	575	95	677

ZnO-based device, up to 575 mV for the Mg_{0.1}Zn_{0.9}O-based one. In order to understand this enhancement of V_{oc} , we determined the band alignment of Cu₂O and Mg_xZn_{1-x}O using the XPS method proposed by Kraut et al. [27] In this method, the valence band offset (ΔE_V) at the Cu₂O-Mg_xZn_{1-x}O heterojunction interface is given by the following equation:

$$\Delta E_V = (E_{Zn2p}^{Mg_xZn_{1-x}O} - E_V^{Mg_xZn_{1-x}O}) - (E_{Cu2p}^{Cu_2O} - E_V^{Cu_2O}) - (E_{Zn2p}^{Mg_xZn_{1-x}O}(i) - E_{Cu2p}^{Cu_2O}(i)) \quad (1)$$

where E_A^B refers the binding energy of core level “A” in the sample “B”, E_V^B refers the valence band maximum (VBM) and $E_A^B(i)$ represents the binding energy of core level “A” in the sample “B” at the interface. Two heterojunctions of Cu₂O-ZnO and Cu₂O-Mg_{0.1}Zn_{0.9}O were chosen for the XPS measurement. Fig. 4a shows the XPS spectra determined from the Cu₂O-ZnO heterojunction. The Cu₂O-Mg_{0.1}Zn_{0.9}O spectra are not shown as they are almost same as that of Cu₂O-ZnO with slightly different binding energy separation values. Based on the XPS data, the corresponding band alignments of Cu₂O-ZnO and Cu₂O-Mg_{0.1}Zn_{0.9}O heterojunctions are schematically drawn as Fig. 4b. From that, we can see the VBOs for Cu₂O-ZnO and Cu₂O-Mg_xZn_{1-x}O are 2.73 and 2.77 eV, respectively. The conduction band offsets (CBOs) are determined to be 1.47 eV for Cu₂O-ZnO and 1.27 eV for Cu₂O-Mg_{0.1}Zn_{0.9}O. The 0.2 eV difference moves the conduction band of Mg_{0.1}Zn_{0.9}O closer to the vacuum level compared to ZnO; we assume that this change in conduction band edge is responsible for the enhancement of V_{oc} . It is difficult to determine the theoretical V_{oc} from this band alignment without knowing the built-in potential V_{bi} determined by the effective work function difference between p

and n semiconductors. Assuming that the Fermi level E_{Fn} in n-Mg_xZn_{1-x}O is close to E_{Cn} (CBM in n-Mg_xZn_{1-x}O), and E_{Fp} in p-Cu₂O is close to E_{Vp} (VBM in p-Cu₂O) due to the high doping level in both n and p materials, the energy difference between E_{Cn} and E_{Vp} would be approximately equal to the V_{bi} , i.e. the upper limit of V_{oc} . With this assumption, the upper limit of theoretical V_{oc} is estimated to be 530 mV for Cu₂O-ZnO and 730 mV for Cu₂O-Mg_{0.1}Zn_{0.9}O, respectively.

As shown in the equivalent circuit of the solar cell in the inset of Fig. 3, the low shunt resistance (R_{sh}) could degrade V_{oc} significantly. R_{sh} is generally caused by parallel high-conductivity paths (PHCPs) through the solar cell, or on the edges of the cell. In our case, the interface defects and grain boundaries of both polycrystalline films in the space charge region (SCR) of the heterojunction could act as PHCPs, thus contributing to the R_{sh} . As shown in Table 1, R_{sh} value increases with increasing Mg concentration, from 189 Ω cm² for ZnO to 677 Ω cm² for Mg_{0.1}Zn_{0.9}O, indicate a decrease of the PHCPs with increasing Mg. In addition to the defects contribution, the surface morphology also impacts the PHCP. Figs. 1b and 1c show different surface morphologies between Mg_xZn_{1-x}O ($x=0.1$) and ZnO ($x=0$) films, which result in the different effective junction area between Mg_xZn_{1-x}O and Cu₂O. The Cu₂O-ZnO heterojunction have a larger effective junction area than that of the Cu₂O-Mg_{0.1}Zn_{0.9}O cell, due to the nanorods-like surface of ZnO in comparison to the relatively smooth surface of Mg_{0.1}Zn_{0.9}O. A larger junction area is favorable for generating more electron/hole pairs, hence a higher photocurrent; however, it would concomitantly possesses more interface defects and grain boundaries. As shown in Table 1, the Cu₂O-ZnO cell has lower R_{sh} due to higher PHCPs than that of Cu₂O-Mg_{0.1}Zn_{0.9}O. The lower R_{sh} in Cu₂O-ZnO degrades V_{oc} values (a deviation of 279 mV from the real V_{oc} to the theoretical one) more than that of Cu₂O-Mg_{0.1}Zn_{0.9}O (a deviation of 155 mV).

Unlike the V_{oc} and R_{sh} , the short circuit current density J_{sc} stops being improved and starts to decrease as the Mg percentage increases to over 4%. The resistivity, ρ , of Mg_xZn_{1-x}O films increases with Mg content (x) from ~ 4 Ω cm ($x=0$) to ~ 63 Ω cm for ($x=0.1$), resulting in increasing in the series resistance R_s (Table 1). With the improved V_{oc} and R_{sh} , the solar conversion efficiency η of devices keep increasing with the increase of Mg content (x) until $x=0.1$. The highest solar conversion efficiency was obtained on the Mg_{0.1}Zn_{0.9}O sample, $\eta_{AM1.5}=0.71\%$, with the $J_{sc}=3.0$ mA/cm² and $V_{oc}=575$ mV.

A solar cell with a higher Mg content of 13% was also fabricated. However, the electrodeposition of Cu₂O became difficult with a small deposition rate and poor control of film uniformity. The reason could be attributed to the rougher surface morphology and higher resistivity of Mg_{0.13}Zn_{0.87}O films ($\rho \sim 78$ Ω cm) in comparison with other Mg_xZn_{1-x}O ($x \leq 0.1$) films. As consequence, the thickness of as-deposited Cu₂O film was low (~ 2.5 μ m), resulted in lower J_{sc} and deteriorated solar cell performances as shown in Fig. 3.

4. Conclusion

In summary, Cu₂O-Mg_xZn_{1-x}O heterojunction solar cells were fabricated on FTO/glass substrates. The effects of Mg composition in Mg_xZn_{1-x}O on the open-circuit voltage of the solar cells were investigated. V_{oc} and $\eta_{AM1.5}$ were enhanced with increasing of Mg content in the Mg_xZn_{1-x}O ($0 \leq x \leq 0.1$). The solar conversion efficiency $\eta_{AM1.5}=0.71\%$, with $J_{sc}=3.0$ mA/cm² and $V_{oc}=575$ mV were obtained in the Cu₂O-Mg_{0.1}Zn_{0.9}O cell. Further increasing of Mg incorporation ($> 10\%$) would increase the resistivity of Mg_xZn_{1-x}O films and degrade the quality of Cu₂O films made by the electrodeposition, therefore, result in poor cell performance. In order to understand the Mg effect on the enhanced V_{oc} , the band alignment

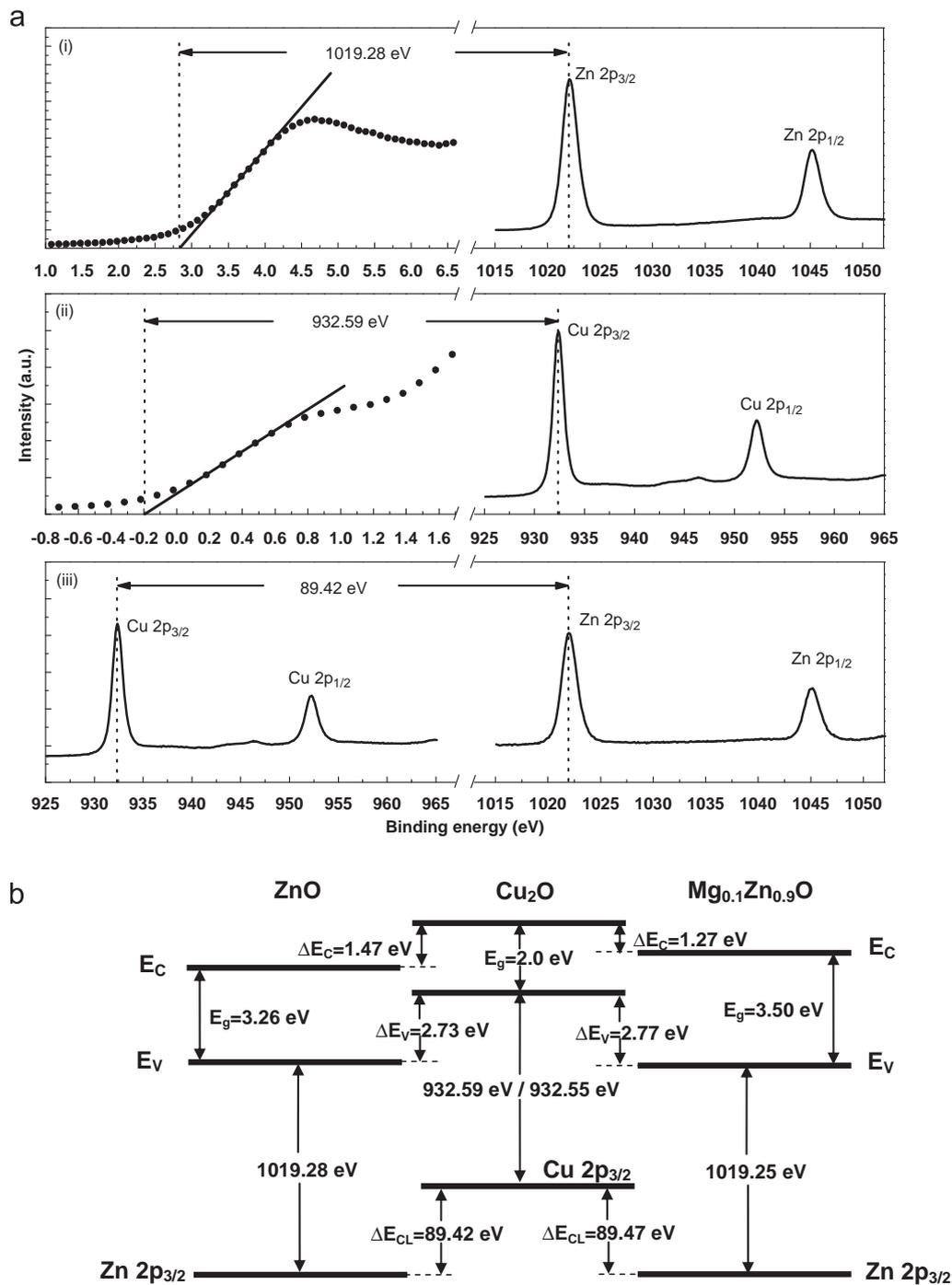


Fig. 4. (a) XPS spectra of a Cu_2O - ZnO heterojunction, showing the binding energy separations (i) between the $\text{Zn } 2p_{3/2}$ core level and the VBM of a bulk ZnO , (ii) between the $\text{Cu } 2p_{3/2}$ core level and the VBM of a bulk Cu_2O film, and (iii) between the $\text{Zn } 2p_{3/2}$ and the $\text{Cu } 2p_{3/2}$ core levels at the heterojunction interface, respectively. (b) Schematic of the flat-band diagrams at the heterojunction interfaces determined from the XPS measurements. For simplicity, the Cu_2O - ZnO and Cu_2O - $\text{Mg}_{0.1}\text{Zn}_{0.9}\text{O}$ interfaces are drawn with Cu_2O in the middle.

of Cu_2O - $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ heterojunction was measured by XPS. It was found that Mg incorporation into ZnO reduced the conduction band offset between $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ and Cu_2O , resulting in an increase of V_{OC} . Furthermore, the Mg incorporation ($0 \leq x \leq 0.1$) increased the R_{sh} , correspondingly improves V_{OC} value.

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